The documentation and process conversion measures necessary to comply with this document shall be completed by 20 January 2014.

INCH-POUND

MIL-PRF-19500/595K 20 November 2013 SUPERSEDING MIL-PRF-19500/595J 25 October 2010

PERFORMANCE SPECIFICATION SHEET

SEMICONDUCTOR DEVICE, REPETITIVE AVALANCHE, FIELD EFFECT, TRANSISTOR, P-CHANNEL, SILICON, TYPES 2N7236, 2N7237, 2N7236U, AND 2N7237U, JAN, JANTX, JANTXV, JANS, JANHC, AND JANKC

This specification is approved for use by all Departments and Agencies of the Department of Defense.

The requirements for acquiring the product described herein shall consist of this specification sheet and MIL-PRF-19500.

1. SCOPE

1.1 <u>Scope</u>. This specification covers the performance requirements for a P-channel, enhancement-mode, MOSFET, power transistor intended for use in high density power switching applications. Four levels of product assurance are provided for each encapsulated device type as specified in MIL-PRF-19500, and two levels of product assurance for each unencapsulated device type die, with avalanche energy ratings (E_{AS} and E_{AR}) and maximum avalanche current (I_{AR}).

1.2 <u>Physical dimensions</u>. See figure 1 (TO-254AA), figure 2 (TO-267AB) for surface mount devices, and figure 3 and 4 for JANHC and JANKC (die) dimensions.

| Туре | P _T (1) T _C = +25°C | P _T T _A = +25°C | R _{θJC} (2) | $\begin{array}{c} \text{Min} \\ V_{(\text{BR})\text{DSS}} \\ V_{\text{GS}} = 0 \\ \text{I}_{\text{D}} = -1.0 \\ \text{mA dc} \end{array}$ | V _{GS} | I _{D1} (3) (4) T _C = +25°C | I _{D2} (3) (4) T _C = +100°C | I _S | I _{DM} (5) | T _J and T _{STG} |
|------------------------------------|---|---|-------------------------|---|-----------------|--|---|----------------|------------------------|---|
| | W | W | <u>°C/W</u> | <u>V dc</u> | <u>V dc</u> | <u>A dc</u> | <u>A dc</u> | <u>A dc</u> | <u>A (pk)</u> | <u>°C</u> |
| 2N7236, 2N7236U 2N7237, 2N7237U | 125 125 | 4.0 4.0 | 1.0 1.0 | -100 -200 | ±20 ±20 | -18 -11 | -11 -7 | -18 -11 | -72 -44 | -55 to +150 -55 to +150 |

1.3 Maximum ratings ($T_c = +25^{\circ}C$, unless otherwise specified).

See notes next page.

* Comments, suggestions, or questions on this document should be addressed to DLA Land and Maritime, ATTN: VAC, P.O. Box 3990, Columbus, OH 43218-3990, or emailed to <u>Semiconductor@dla.mil</u>. Since contact information can change, you may want to verify the currency of this address information using the ASSIST Online database at <u>https://assist.dla.mil/</u>.

1.3 Maximum ratings - continued.

| Туре | I _{AR} | E _{AS} | E _{AR} | $V_{GS} =$ | max (6) -10 V dc = I _{D2} |
|------------------------------------|-----------------|-----------------|-----------------|------------------------|--|
| | | | | T _J = +25°C | T _J = +150°C |
| | <u>A</u> | <u>mJ</u> | <u>mJ</u> | <u>ohm</u> | <u>ohm</u> |
| 2N7236, 2N7236U 2N7237, 2N7237U | -18 -11 | 500 500 | 12.5 12.5 | 0.20 0.51 | 0.400 1.122 |

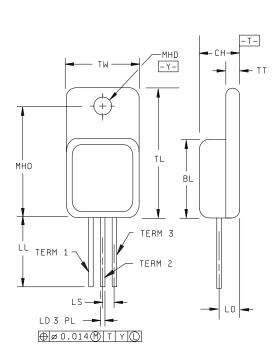
- (1)
- Derate linearly 1.0 W/°C for $T_c > +25$ °C. See figure 5, thermal impedance curves. The following formula derives the maximum theoretical I_D limit. I_D is limited by package and internal wires and may be limited by pin diameter: (2) (3)

$$I_{\rm D} = \sqrt{\frac{T_{\rm JM} - T_{\rm C}}{\left(R_{\rm 0JC}\right) x \left(R_{\rm DS}({\rm on}) {\rm at} T_{\rm JM}\right)}}$$

- (4) See figure 6, maximum drain current graphs.
- (5) $I_{DM} = 4 \times I_{D1}$ as calculated in footnote (3).
- Pulsed (see 4.5.1). (6)
- 1.4 <u>Primary electrical characteristics</u>. $T_C = +25^{\circ}C$ (unless otherwise specified).

| Туре | $\begin{array}{l} \text{Min } V_{(\text{BR})\text{DSS}} \\ V_{\text{GS}} = 0 \\ \text{I}_{\text{D}} = -1.0 \text{ mA dc} \end{array}$ | $V_{\text{DS}} \geq V_{\text{GS}}$ | | $\begin{array}{c} \text{Max } I_{\text{DSS1}} \\ V_{\text{GS}} = 0 \\ V_{\text{DS}} = 80 \text{ percent} \\ \text{ of rated } V_{\text{DS}} \end{array}$ | $Max r_{DS(on)1} (1)$ $I_{D} = I_{D2}$ $V_{GS} = 10 V$ |
|------------------------------------|---|------------------------------------|---------------------------|--|--|
| | <u>V dc</u> | <u>Min</u> | <u>V dc</u> <u>Max</u> | <u>μA dc</u> | <u>Ohms</u> |
| 2N7236, 2N7236U 2N7237, 2N7237U | -100 -200 | -2.0 -2.0 | -4.0 -4.0 | -25 -25 | 0.20 0.51 |

(1) Pulsed (see 4.5.1).

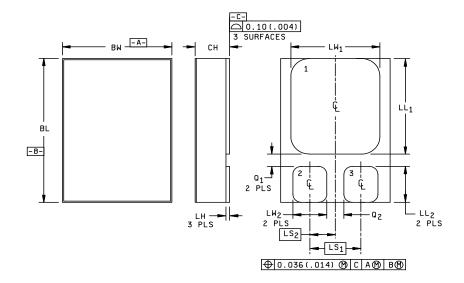


| Ltr | Inc | hes | Millir | neters | Notes | |
|-----------|----------|------|--------|--------|-------|--|
| | Min | Max | Min | Max | | |
| BL | .535 | .545 | 13.59 | 13.84 | | |
| СН | .249 | .260 | 6.32 | 6.60 | | |
| LD | .035 | .045 | 0.89 | 1.14 | | |
| LL | .510 | .570 | 12.95 | 14.48 | 3 | |
| LO | .150 | BSC | 3.81 | | | |
| LS | .150 BSC | | 3.81 | | | |
| MHD | .139 | .149 | 3.53 | 3.78 | | |
| мно | .665 | .685 | 16.89 | 17.40 | | |
| TL | .790 | .800 | 20.07 | 20.32 | 4 | |
| TT | .040 | .050 | 1.02 | 1.27 | 4 | |
| тw | .535 | .545 | 13.59 | 13.84 | | |
| Term 1 | | | | | | |
| Term 2 | | | | | | |
| Term 3 | | G | ate | | | |

NOTES:

- 1. Dimensions are in inches.
- Millimeters are given for general information only.
 Protrusion thickness of ceramic eyelets included in dimension LL.
- 4. All terminals are isolated from case.
- 5. In accordance with ASME Y14.5M, diameters are equivalent to ϕx symbology.

FIGURE 1. Physical dimensions for TO-254AA (2N7236 and 2N7237).

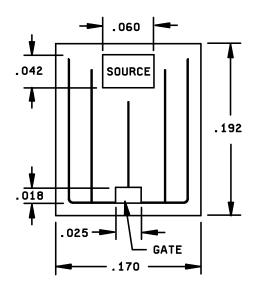


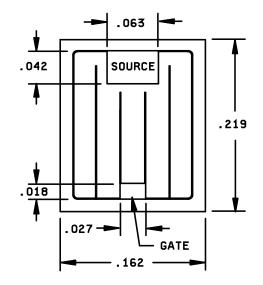
| | | Dimensi | ons | | |
|-----------------|----------|---------|----------|--------|--|
| Letter | Inc | hes | Millin | neters | |
| | Min | Max | Min | Max | |
| BL | .620 | .630 | 15.75 | 16.00 | |
| BW | .445 | .455 | 11.30 | 11.56 | |
| CH | | .142 | | 3.60 | |
| LH | .010 | .020 | 0.26 | 0.50 | |
| LL ₁ | .410 | .420 | 10.41 | 10.67 | |
| LL ₂ | .152 | .162 | 3.86 | 4.11 | |
| LS ₁ | .210 | BSC | 5.33 BSC | | |
| LS ₂ | .105 BSC | | 2.67 BSC | | |
| LW ₁ | .370 | .380 | 9.40 | 9.65 | |
| LW ₂ | .135 | .145 | 3.43 | 3.68 | |
| Q ₁ | .030 | | 0.76 | | |
| Q ₂ | .035 | | 0.89 | | |
| Term 1 | Drain | | | | |
| Term 2 | Gate | | | | |
| Term 3 | | | Source | | |

NOTES:

- 1. Dimensions are in inches.
- 2. Millimeters are given for information only.
- 3. The lid shall be electrically isolated from the drain, gate and source.
- 4. In accordance with ASME Y14.5M, diameters are equivalent to ϕx symbology.

FIGURE 2. Dimensions and configuration of surface mount package outline (TO-267AB), 2N7236U and 2N7237U).





2N7236

2N7237

A version

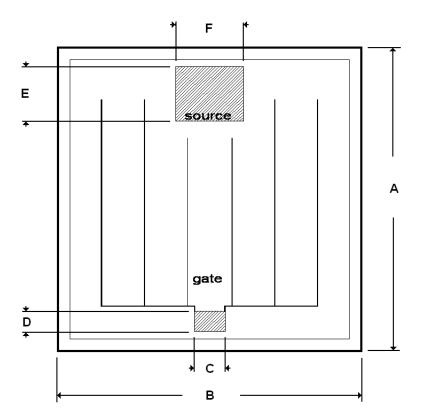
| Inches .018 | mm 0.46 |
|----------------|------------|
| .025 | 0.64 |
| .027 | 0.69 |
| .042 | 1.07 |
| .060 | 1.52 |
| .063 | 1.60 |
| .162 | 4.11 |
| .170 | 4.32 |
| .192 | 4.88 |
| .219 | 5.56 |

NOTES:

- 1. Dimensions are in inches.
- 2. Millimeters are given for information only.
- 3. Unless otherwise specified, tolerance is \pm .005 inch (0.13 mm).
- 4. Physical characteristics of the die thickness = .0187 inch (0.47 mm).
- 5. Back metal: Cr Ni Ag.
- 6. Top metal: Al.
- 7. Back contact: Drain.
- 8. See 6.5 for ordering information.

FIGURE 3. Physical dimensions JANHCA and JANKCA die.





| | Dimensions - 2N7236 | | | | | | |
|-----|---------------------|------|--------|--------|--|--|--|
| Ltr | Inc | hes | Millim | neters | | | |
| | Min | Max | Min | Max | | | |
| A | .177 | .183 | 4.50 | 4.65 | | | |
| В | .177 .183 | | 4.50 | 4.65 | | | |
| С | .030 | .034 | .76 | .86 | | | |
| D | .017 | .022 | .43 | .56 | | | |
| E | .034 | .038 | .86 | .97 | | | |
| F | .047 | .051 | 1.19 | 1.30 | | | |

NOTES:

1. Dimensions are in inches.

- 2. Millimeters are given for general information only.
- 3. Unless otherwise specified, tolerance is \pm .005 inch (0.13 mm).
- 4. The physical characteristics of the die are: The back metals are chromium, nickel, and silver and the back contact is the drain. The top metal is aluminum.
- 5. Die thickness is .015 inch (0.38 mm) ±.001 inch (0.025 mm).

FIGURE 4 . JANHCB and JANKCB (B-version) die dimensions for 2N7236 only.

2. APPLICABLE DOCUMENTS

2.1 <u>General</u>. The documents listed in this section are specified in sections 3, 4, or 5 of this specification. This section does not include documents cited in other sections of this specification or recommended for additional information or as examples. While every effort has been made to ensure the completeness of this list, document users are cautioned that they must meet all specified requirements of documents cited in sections 3, 4, or 5 of this specification, whether or not they are listed.

2.2 Government documents.

2.2.1 <u>Specifications, standards, and handbooks</u>. The following specifications, standards, and handbooks form a part of this document to the extent specified herein. Unless otherwise specified, the issues of these documents are those cited in the solicitation or contract.

DEPARTMENT OF DEFENSE SPECIFICATIONS

MIL-PRF-19500 - Semiconductor Devices, General Specification for.

DEPARTMENT OF DEFENSE STANDARDS

MIL-STD-750 - Test Methods for Semiconductor Devices.

* (Copies of these documents are available online at <u>http://quicksearch.dla.mil/</u> or <u>https://assist.dla.mil/</u> or from the Standardization Document Order Desk, 700 Robbins Avenue, Building 4D, Philadelphia, PA 19111-5094.)

2.3 <u>Order of precedence</u>. Unless otherwise noted herein or in the contract, in the event of a conflict between the text of this document and the references cited herein, the text of this document takes precedence. Nothing in this document, however, supersedes applicable laws and regulations unless a specific exemption has been obtained.

3. REQUIREMENTS

3.1 General. The individual item requirements shall be as specified in MIL-PRF-19500 and as modified herein.

3.2 <u>Qualification</u>. Devices furnished under this specification shall be products that are manufactured by a manufacturer authorized by the qualifying activity for listing on the applicable qualified manufacturer's list (QML) before contract award (see 4.2 and 6.3).

3.3 <u>Abbreviations, symbols, and definitions</u>. Abbreviations, symbols, and definitions used herein shall be as specified in MIL-PRF-19500 and as follows.

nC nano Coulomb.

3.4 <u>Interface and physical dimensions</u>. Interface and physical dimensions shall be as specified in MIL-PRF-19500, and on figures 1 (TO-254AA), 2 (TO-267AB, surface mount), and 3 and 4 (die) herein. Methods used for electrical isolation of the terminal feedthroughs shall employ materials that contain a minimum of 90 percent AL_2O_3 (ceramic). Examples of such construction techniques are metallized ceramic eyelets or ceramic walled packages.

3.4.1 Lead formation and finish. Lead finish shall be solderable in accordance with MIL-PRF-19500, MIL-STD-750, and herein. Where a choice of lead formation or finish is desired, it shall be specified in the acquisition document (see 6.2). When lead formation is performed, as a minimum, the vendor shall perform 100 percent hermetic seal in accordance with screen 14 of table E-IV of MIL-PRF-19500 and 100 percent dc testing in accordance with table I, subgroup 2 herein.

3.4.2 Internal construction. Multiple chip construction is not permitted.

3.5 Electrostatic discharge protection. The devices covered by this specification require electrostatic protection.

3.5.1 <u>Handling</u>. MOS devices must be handled with certain precautions to avoid damage due to the accumulation of static charge. However, the following handling practices are recommended (see 3.5).

- a. Devices should be handled on benches with conductive and grounded surface.
- b. Ground test equipment, tools, and personnel handling devices.
- c. Do not handle devices by the leads.
- d. Store devices in conductive foam or carriers.
- e. Avoid use of plastic, rubber, or silk in MOS areas.
- f. Maintain relative humidity above 50 percent if practical.
- g. Care should be exercised, during test and troubleshooting, to apply not more than maximum rated voltage to any lead.
- h. Gate must be terminated to source. $R \le 100 \text{ k}\Omega$, whenever bias voltage is to be applied drain to source.

3.6 <u>Electrical performance characteristics</u>. Unless otherwise specified herein, the electrical performance characteristics are as specified in 1.3, 1.4, and table I.

3.7 Electrical test requirements. The electrical test requirements shall be as specified in table I.

3.8 <u>Marking</u>. Marking shall be in accordance with MIL-PRF-19500, except at the option of the manufacturer, the country of origin and/or the manufacturers identification may be omitted from the body of the transistor.

3.9 <u>Workmanship</u>. Semiconductor devices shall be processed in such a manner as to be uniform in quality and shall be free from other defects that will affect life, serviceability, or appearance.

4. VERIFICATION

- 4.1 <u>Classification of inspections</u>. The inspection requirements specified herein are classified as follows:
 - a. Qualification inspection (see 4.2).
 - b. Screening (see 4.3).
 - c. Conformance inspection (see 4.4 and tables I and II).

4.2 <u>Qualification inspection</u>. Qualification inspection shall be in accordance with MIL-PRF-19500. Alternate flow is allowed for qualification inspection in accordance with of MIL-PRF-19500.

4.2.1 <u>JANHC and JANKC qualification</u>. JANHC and JANKC qualification inspection shall be in accordance with MIL-PRF-19500.

4.2.2 <u>Group E qualification</u>. Group E inspection shall be performed for qualification or re-qualification only. In case qualification was awarded to a prior revision of the specification sheet that did not request the performance of table II tests, the tests specified in table II herein that were not performed in the prior revision shall be performed on the first inspection lot of this revision to maintain qualification.

4.3 <u>Screening (JANTX, JANTXV, and JANS levels only</u>). Screening shall be in accordance with table E-IV of MIL-PRF-19500, and as specified herein. The following measurements shall be made in accordance with table I herein. Devices that exceed the limits of table I herein shall not be acceptable.

| Screen (see table E-IV | Measurement | | | | | |
|------------------------------|--|--|--|--|--|--|
| of MIL-PRF-19500) (1) (2) | JANS level | JANTX and JANTXV level | | | | |
| (3) | Gate stress test (see 4.3.2) | Gate stress test (see 4.3.2) | | | | |
| (3) | Method 3470 of MIL-STD-750. (see 4.3.3) | Method 3470 of MIL-STD-750. (see 4.3.3) | | | | |
| (3) 3c | Method 3161 of MIL-STD-750 (see 4.3.4) | Method 3161 of MIL-STD-750 (see 4.3.4) | | | | |
| 9 | I _{GSSF1} , I _{GSSR1} , I _{DSS1} , subgroup 2 of table I herein | Subgroup 2 of table I herein | | | | |
| 10 | Method 1042 of MIL-STD-750, test condition B | Method 1042 of MIL-STD-750, test condition B | | | | |
| 11 | IGSSF1, IGSSR1, IDSS1, rDS(on)1, VGS(th)1 Subgroup 2 of table I herein. $\Delta I_{GSSF1} = +20$ nA dc or ±100 percent of initial value, whichever is greater. $\Delta I_{GSSR1} = -20$ nA dc or ±100 percent of initial value, whichever is greater. $\Delta I_{DSS1} = \pm 25 \ \mu A \ dc \ or \pm 100 \ percent of$ initial value, whichever is greater. | IGSSF1, IGSSR1, IDSS1, IDS(on)1, VGS(th)1 Subgroup 2 of table I herein. | | | | |
| 12 | Method 1042 of MIL-STD-750, test condition A | Method 1042 of MIL-STD-750, test condition A or $T_A = +175^{\circ}C$ and t = 48 hours | | | | |
| 13 | Subgroup 2 and 3 of table I herein. $\Delta I_{GSSF1} = +20$ nA dc or ±100 percent of initial value, whichever is greater. $\Delta I_{GSSR1} = -20$ nA dc or ±100 percent of initial value, whichever is greater. $\Delta I_{DSS1} = \pm 25 \ \mu$ A dc or ±100 percent of initial value, whichever is greater. $\Delta r_{DS(on)1} = \pm 20$ percent of initial value. $\Delta V_{GS(th)1} = \pm 20$ percent of initial value. For TO-254AA packages: Method 1081 of MIL-STD-750 (see 4.3.5), Endpoints: Subgroup 2 of table I herein. | Subgroup 2 of table I herein. $\Delta I_{GSSF1} = +20$ nA dc or ±100 percent of initial value, whichever is greater. $\Delta I_{GSSR1} = -20$ nA dc or ±100 percent of initial value, whichever is greater. $\Delta I_{DSS1} = \pm 25 \ \mu$ A dc or ±100 percent of initial value, whichever is greater. $\Delta r_{DS(on)1} = \pm 20$ percent of initial value. $\Delta V_{GS(th)1} = \pm 20$ percent of initial value. For TO-254AA packages: Method 1081 of MIL-STD-750 (see 4.3.5), Endpoints: Subgroup 2 of table I herein. | | | | |

(1) At the end of the test program, I_{GSSF1} , I_{GSSR1} , and I_{DSS1} are measured.

*

(3) Shall be performed anytime after temperature cycling, screen 3a; JANTX and JANTXV do not need to be repeated in screening requirements.

⁽²⁾ An out-of-family program to characterize I_{GSSF1} , I_{GSSF1} , I_{DSS1} , and $V_{GS(th)1}$ shall be invoked.

4.3.1 <u>Screening (JANHC and JANKC)</u>. Screening of die shall be in accordance with appendix G of MIL-PRF-19500. As a minimum, die shall be 100 percent probed in accordance with table I, subgroup 2, except test current shall not exceed 20 A.

4.3.2 <u>Gate stress test</u>. Apply V_{GS} = 30 V minimum for t = 250 µs minimum.

4.3.3 Single pulse avalanche energy (E_{AS}).

- a. Peak current (I_D)I_{AR}(max).
- b. Peak gate voltage (V_{GS}).....-10 V.
- c. Gate to source resistor (R_Gs)25 \leq R_Gs \leq 200 Ω .
- d. Initial case temperature+25°C +10°C, -5°C.
- e. Inductance $\left[\frac{2E_{AS}}{(I_{D1})^2}\right]\left[\frac{V_{BR} V_{DD}}{V_{BR}}\right]$ mH minimum.

f. Number of pulses to be applied1 pulse minimum.

g. Supply voltage (V_{DD})......25 V for 2N7236, 2N7236U, -50 V for 2N7237, 2N7237U.

4.3.4 <u>Thermal impedance</u>. The thermal impedance measurements shall be performed in accordance with method 3161 of MIL-STD-750 using the guidelines in that method for determining I_M , I_H , t_H , t_{SW} , (and V_H where appropriate). Measurement delay time (t_{MD}) = 60 μ s max. See table II, group E, subgroup 4 herein.

4.3.5 Dielectric withstanding voltage.

- a. Magnititude of test voltage......900 V dc.
- b. Duration of application of test voltage......15 seconds (min).
- c. Points of application of test voltage.....All leads to case (bunch connection).
- d. Method of connection......Mechanical.

e. Kilovolt-ampere rating of high voltage source......1,200 V/1.0 mA (min).

- f. Maximum leakage current.....1.0 mA.
- g. Voltage ramp up time......500 V/second.

4.4 <u>Conformance inspection</u>. Conformance inspection shall be in accordance with MIL-PRF-19500.

4.4.1 <u>Group A inspection</u>. Group A inspection shall be conducted in accordance with MIL-PRF-19500, and table I herein. End-point electrical measurements shall be in accordance with table I, subgroup 2 herein.

4.4.2 <u>Group B inspection</u>. Group B inspection shall be conducted in accordance with the conditions specified for subgroup testing in table E-VIA (JANS) and table E-VIB (JAN, JANTX, and JANTXV) of MIL-PRF-19500 and as follows. Electrical measurements (end-points) shall be in accordance with table I, subgroup 2 herein.

4.4.2.1 Group B inspection, table E-VIA (JANS) of MIL-PRF-19500.

| <u>Subgroup</u> | Method | Condition |
|-----------------|---------------|--|
| B3 | 1051 | Test condition G. |
| B3 | 2037 | Test condition D. All internal wires for each device shall be pulled separately. If group B3 is to be continued to C6, strength test may be performed after C6. |
| B4 | 1042 | Test condition D. The heating cycle shall be 1 minute minimum. No heat sink nor forced air cooling on the device shall be permitted during the "on" cycle. |
| B5 | 1042 | A separate sample may be pulled for each test. Accelerated steady-state reverse bias; test condition A, V_{DS} = rated, T_A = +175°C, t = 120 hours, read and record $V_{BR(DSS)}$ (pre and post) at I_D = -1 mA dc. Read and record I_{DSS} (pre and post) in accordance with table I, subgroup 2 herein. $V_{BR(DSS)}$ delta cannot exceed 10 percent. |
| B5 | 2037 | Bond strength; test condition D. |
| B6 | | Not applicable. |
| 4.4.2.2 Group E | 3 inspection, | table E-VIB (JAN, JANTX and JANTXV) of MIL-PRF-19500. |

| Subgroup | Method | Condition |
|----------|--------|--|
| B2 | 1051 | Test condition G. |
| B3 | 1042 | Test condition D. The heating cycle shall be 1 minute minimum. |

4.4.3 <u>Group C inspection</u>. Group C inspection shall be conducted in accordance with the conditions specified for subgroup testing in table E-VII of MIL-PRF-19500, and as follows. Electrical measurements (end-points) shall be in accordance with table I, subgroup 2 herein.

| <u>Subgroup</u> | Method | Conditions |
|-----------------|--------|--|
| C2 | 2036 | Test condition A; weight = 10 pounds, $t = 10$ s (not applicable for surface mount devices). |
| C5 | 3161 | See 4.3.4, R ₀ JC(max) = 1.0°C/W. |
| C6 | 1042 | Test condition D. The heating cycle shall be 1 minute minimum. |

4.4.4 <u>Group E inspection</u>. Group E inspection shall be conducted in accordance with the conditions specified for subgroup testing in table E-IX of MIL-PRF-19500 and as specified in table II herein. Electrical measurements (end-points) shall be in accordance with table I, subgroup 2 herein.

4.5 <u>Methods of inspection</u>. Methods of inspection shall be as specified in the appropriate tables and as follows.

4.5.1 Pulse measurements. Conditions for pulse measurement shall be as specified in section 4 of MIL-STD-750.

TABLE I. Group A inspection.

| Inspection <u>1</u> / | | MIL-STD-750 | Symbol | | nits | Unit |
|---|--------|--|----------------------|--------------|--------------|--------------|
| | Method | Condition | | Min | Max | |
| Subgroup 1 | | | | | | |
| Visual and mechanical inspection | 2071 | | | | | |
| Subgroup 2 | | | | | | |
| Thermal impedance 2/ | 3161 | See 4.3.4 | Z _{θJC} | | | °C/W |
| Breakdown voltage, drain to source | 3407 | Bias condition C, $V_{GS} = 0V$, $I_{D} = 1$ mA dc | V (BR)DSS | | | |
| 2N7236, 2N7236U 2N7237, 2N7237U | | | | -100 -200 | | V dc V dc |
| Gate to source voltage (threshold) | 3403 | $V_{DS} \geq V_{GS}, \ I_D =25 \ mA$ | $V_{GS(th)1}$ | -2.0 | -4.0 | V dc |
| Gate reverse current | 3411 | Bias condition C, V_{GS} = +20 V dc, V_{DS} = 0 V dc | I _{GSSF1} | | +100 | nA dc |
| Gate reverse current | 3411 | Bias condition C, V_{GS} = -20 V dc, V_{DS} = 0 V dc | I _{GSSR1} | | -100 | nA dc |
| Drain current | 3413 | Bias condition C, $V_{GS} = 0 V dc$, $V_{DS} = 80$ percent of rated V_{DS} | I _{DSS1} | | -25 | $\mu A \ dc$ |
| Static drain to source | 3421 | $V_{GS} = 10 V dc$, condition A, pulsed | r _{DS(on)1} | | | |
| on-state resistance 2N7236, 2N7236U 2N7237, 2N7237U | | (see 4.5.1), I_D = rated I_{D2} (see 1.3) | | | 0.20 0.51 | Ω Ω |
| Static drain to source on-state resistance | 3421 | V_{GS} = -10 V dc, condition A, pulsed (see 4.5.1), I_D = rated I_{D1} | r _{DS(on)2} | | | |
| 2N7236, 2N7236U 2N7237, 2N7237U | | (see 1.3) | | | 0.22 0.52 | Ω Ω |
| Forward voltage (source drain diode) | 4011 | $V_{GS} = 0 V dc$ $I_D = rated I_{D1}$, pulsed (see 4.5.1) | V_{SD} | | | |
| 2N7236, 2N7236U 2N7237, 2N7237U | | $10 - 10 = 100 \text{ m}^{-1}$, puiseu (see 4.3.1) | | | -5.0 -5.0 | V V |

See footnotes at end of table.

TABLE I. Group A inspection - Continued.

| Inspection <u>1</u> / | MIL-STD-750 | | Symbol | Limits | | Unit |
|--|-------------|--|----------------------|--------|--------------|--------|
| | Method | Condition | | Min | Max | |
| Subgroup 3 | | | | | | |
| High temperature operation: | | $T_{C} = T_{J} = +125^{\circ}C$ | | | | |
| Gate reverse current | 3411 | Bias condition C $V_{GS} = \pm 20 \text{ V dc}, V_{DS} = 0 \text{ V dc},$ | I _{GSS2} | | ±200 | nA do |
| Drain current | 3413 | Bias condition C, V_{GS} = 0 V dc, V_{DS} = 100 percent of rated V_{DS} | I _{DSS2} | | -1.0 | mA do |
| Drain current | 3413 | Bias condition C, $V_{GS} = 0 V dc$, $V_{DS} = 80$ percent of rated V_{DS} | I _{DSS3} | | -0.25 | mA de |
| Gate to source voltage (threshold) | 3403 | $V_{DS} \geq V_{GS}, \ I_D = -0.25 \ mA$ | $V_{GS(th)2}$ | -1.0 | | V dc |
| Static drain to source on-state resistance | 3421 | Condition A. $V_{GS} = -10 \text{ V dc}$, pulsed (see 4.5.1), $I_D = \text{rated } I_{D2}$ (see 1.3) | r _{DS(on)3} | | | |
| 2N7236, 2N7236U 2N7237, 2N7237U | | (566 1.3) | | | 0.34 1.10 | Ω Ω |
| Low temperature operation: | | $T_{C} = T_{J} = -55^{\circ}C$ | | | | |
| Gate to source voltage (threshold) | 3403 | $V_{DS} \geq V_{GS}, \ I_D = -0.25 \ mA$ | $V_{GS(\text{th})3}$ | | -5.0 | V dc |
| Subgroup 4 | | | | | | |
| Switching time test | 3472 | $ I_D = rated I_{D2} (see 1.3), V_{GS} = -10 \\ V dc, gate drive impedance = 9.1 \\ \Omega, V_{DD} = 50 \text{ percent of } V_{BR(DSS)} $ | | | | |
| Turn-on delay time | | | t _{d(on)} | | 35 | ns |
| Rise time | | | tr | | 85 | ns |
| Turn-off delay time | | | t _{d(off)} | | 85 | ns |
| Fall time | | | t _f | | 65 | ns |

See footnotes at end of table.

TABLE I. Group A inspection - Continued.

| Inspection <u>1</u> / | MIL-STD-750 | | MIL-STD-750 Limits | | nits | Unit |
|---|-------------|--|--------------------|-----|------------|----------|
| | Method | Condition | | Min | Max | |
| Subgroup 5 | | | | | | |
| Safe operating area test (high voltage) | 3474 | See figure 7; $t_p = 10 \text{ ms}$, $V_{DS} = 80$ percent of rated $V_{BR(DSS)}$, $V_{DS} = 200 \text{ V}$ maximum | | | | |
| Electrical measurements | | See table I, subgroup 2 | | | | |
| Subgroup 6 | | | | | | |
| Not applicable | | | | | | |
| Subgroup 7 | | | | | | |
| Gate charge | 3471 | Condition B | | | | |
| On-state gate charge 2N7236, 2N7236U 2N7237, 2N7237U | | | Q _{g(on)} | | 60 60 | nC nC |
| Gate to source charge 2N7236, 2N7236U 2N7237, 2N7237U | | | Q _{gs} | | 13 15 | nC nC |
| Gate to drain charge 2N7236, 2N7236U 2N7237, 2N7237U | | | Q _{gd} | | 35.2 38 | nC nC |
| Reverse recovery time | 3473 | Condition A. $d_i/d_t \le 100 \text{ A}/\mu\text{s}, V_{DD} \le 30 \text{ V},$ | t _{rr} | | | |
| 2N7236, 2N7236U 2N7237, 2N7237U | | $I_D = I_{D1}$, (see 1.3) | | | 280 440 | ns ns |

1/ For sampling plan, see MIL-PRF-19500.
 2/ This test required for the following end-point measurements only: Group B, subgroups 2 and 3 (JAN, JANTX, and JANTXV). Group B, subgroups 3 and 4 (JANS). Group C, subgroups 2 and 6. Group E, subgroup 1.

| Inspection | MIL-STD-750 | | Sampling | |
|--|-------------|--|---------------------|--|
| | Method | Conditions | plan | |
| Subgroup 1 | | | 45 devices c = 0 | |
| Temperature cycling | 1051 | 500 cycles, test condition G | 0 - 0 | |
| Hermetic seal Fine leak Gross leak | 1071 | As applicable | | |
| Electrical measurements | | See table I, subgroup 2 | | |
| Subgroup 2 1/ | | | 45 devices | |
| Steady-state reverse bias | 1042 | Condition A, 1,000 hours | c = 0 | |
| Electrical measurements | | See table I, subgroup 2 | | |
| Steady-state gate bias | 1042 | Condition B, 1,000 hours | | |
| Electrical measurements | | See table I, subgroup 2 | | |
| Subgroup 4 | | | Sample size N/A | |
| Thermal impedance curves | | See MIL-PRF-19500. | IN/A | |
| Subgroup 5 | | | | |
| Not applicable | | | | |
| Subgroup 10 | | | 22 devices | |
| Commutating diode for safe operating area test procedure for measuring dv/dt during reverse recovery of power MOSFET transistors or insulated gate bipolar transistors | 3476 | Test conditions shall be derived by the manufacturer | c = 0 | |

TABLE II. Group E inspection (all quality levels) for qualification or re-qualification only.

See footnote at end of table.

| Inspection | | Sampling | |
|--|--------|---|--------------------|
| | Method | Conditions | plan |
| Subgroup 11 Repetitive avalanche energy | 3469 | Peak current $I_{AR} = I_D$; peak gate voltage $V_{GS} = -10 \text{ V}$; gate to source resistor, $R_{GS} 25 \le R_{GS} \le 200 \text{ ohms}$; temperature = $T_J = +150^{\circ}\text{C} + 0, -10^{\circ}\text{C}$. Inductance = $\left[\frac{2E_{AR}}{(I_{D1})^2}\right]\left[\frac{V_{BR} - V_{DD}}{V_{BR}}\right]$ mH minimum Number of pulses to be applied = 3.6 X 10 ⁸ ; supply voltage (V_{DD}) = -25 V for 2N7236 and 2N7236U, (V_{DD}) = -50 V for 2N7237 and 2N7237U, time in avalanche = 2 µs min., 20 µs max., frequency = 500 Hz minimum. | 5 devices c = 0 |
| Electrical measurements | | See table I, subgroup 2 | |

TABLE II. Group E inspection (all quality levels) for qualification or re-qualification only - Continued.

 $\underline{1}$ / A separate sample for each test may be pulled.

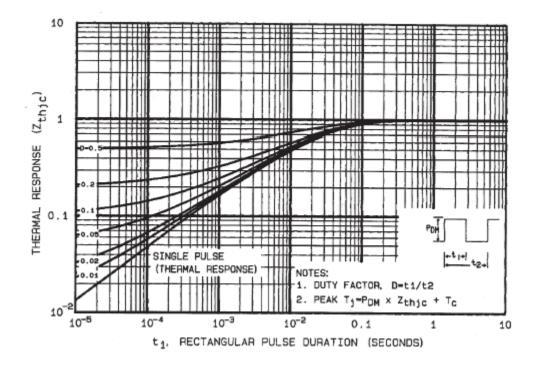


FIGURE 5. Thermal impedance curves.

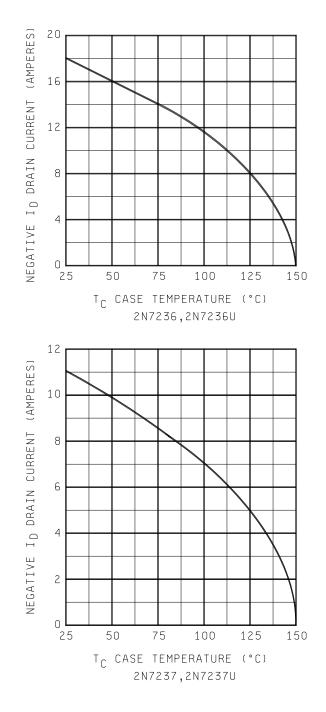
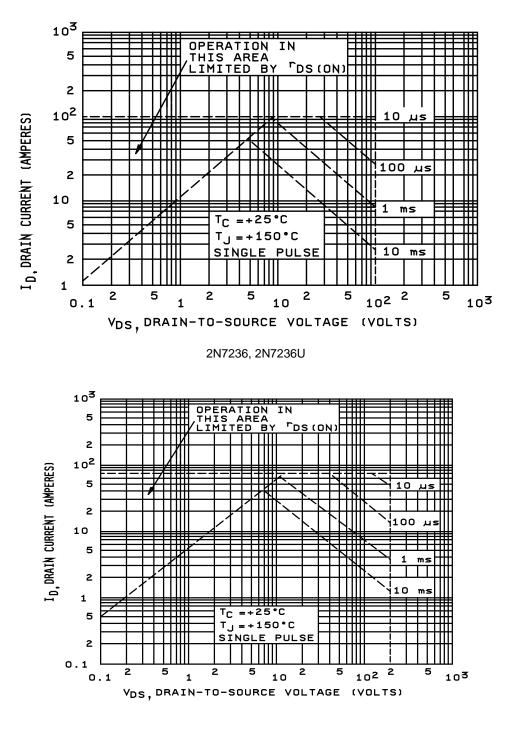


FIGURE 6. Maximum drain current versus case temperature graphs.



2N7237, 2N7237U

FIGURE 7. Safe operating area graphs.

5. PACKAGING

5.1 <u>Packaging</u>. For acquisition purposes, the packaging requirements shall be as specified in the contract or order (see 6.2). When packaging of materiel is to be performed by DoD or in-house contractor personnel, these personnel need to contact the responsible packaging activity to ascertain packaging requirements. Packaging requirements are maintained by the Inventory Control Point's packaging activities within the Military Service or Defense Agency, or within the Military Service's system commands. Packaging data retrieval is available from the managing Military Department's or Defense Agency's automated packaging files, CD-ROM products, or by contacting the responsible packaging activity.

6. NOTES

(This section contains information of a general or explanatory nature that may be helpful, but is not mandatory. The notes specified in MIL-PRF-19500 are applicable to this specification.)

6.1 <u>Intended use</u>. Semiconductors conforming to this specification are intended for original equipment design applications and logistic support of existing equipment.

6.2 <u>Acquisition requirements</u>. Acquisition documents should specify the following:

- a. Title, number, and date of this specification.
- b. Packaging requirements (see 5.1).
- c. Lead finish (see 3.4.1).
- d. Product assurance level and type designator.
- e. Type designation and product assurance level and for die acquisition, specify the JANHC or JANKC letter version (see figure 3, 4, and 6.5).

* 6.3 <u>Qualification</u>. With respect to products requiring qualification, awards will be made only for products which are, at the time of award of contract, qualified for inclusion in Qualified Manufacturers List (QML 19500) whether or not such products have actually been so listed by that date. The attention of the contractors is called to these requirements, and manufacturers are urged to arrange to have the products that they propose to offer to the Federal Government tested for qualification in order that they may be eligible to be awarded contracts or orders for the products covered by this specification. Information pertaining to qualification of products may be obtained from DLA Land and Maritime, ATTN: VQE, P.O. Box 3990, Columbus, OH 43218-3990 or e-mail <u>vqe.chief@dla.mil</u>. An online listing of products qualified to this specification may be found in the Qualified Products Database (QPD) at https://assist.dla.mil.

6.4 <u>Substitution information</u>. Devices covered by this specification are substitutable for the manufacturer's and user's Part or Identifying Number (PIN). This information in no way implies that manufacturer's PIN's are suitable as a substitute for the military PIN.

| Military PIN | Manufactu | rer's CAGE | Manufacturer's and user's PIN |
|--------------|-----------|------------|-------------------------------|
| 2N7236 | 43611 | 59993 | IRFM9140 |
| 2N7237 | | 59993 | IRFM9240 |
| 2N7236U | 43611 | 59993 | IRFM9140 |
| 2N7237U | | 59993 | IRFM9240 |

6.5 <u>Suppliers of JANHC and JANKC die</u>. The qualified die suppliers with the applicable letter version (example JANHCA2N7236) will be identified on the QML.

| JANC ordering information | | | | |
|---------------------------|--------------|--------------|--|--|
| Military PIN | Manufacturer | | | |
| - | 59993 | 43611 | | |
| 2N7236 | JANHCA2N7236 | JANHCB2N7236 | | |
| | JANKCA2N7236 | JANKCB2N7236 | | |
| 2N7237 | JANHCA2N7237 | | | |
| | JANKCA2N7237 | | | |

6.6 <u>Changes from previous issue</u>. The margins of this specification are marked with asterisks to indicate where changes from the previous issue were made. This was done as a convenience only and the Government assumes no liability whatsoever for any inaccuracies in these notations. Bidders and contractors are cautioned to evaluate the requirements of this document based on the entire content irrespective of the marginal notations and relationship to the last previous issue.

Custodians: Army - CR Navy - EC Air Force - 85 NASA - NA DLA - CC Preparing activity: DLA - CC

(Project 5961-2013-113)

Review activities: Army - MI, SM Navy - AS, MC Air Force - 19, 99

* NOTE: The activities listed above were interested in this document as of the date of this document. Since organizations and responsibilities can change, you should verify the currency of the information above using the ASSIST Online database at https://assist.dla.mil/.